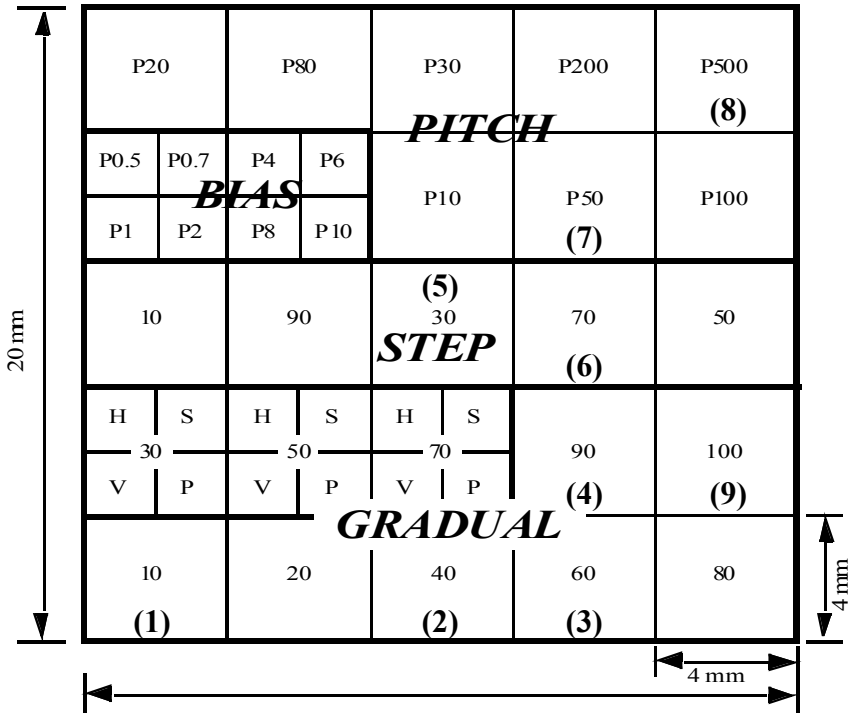
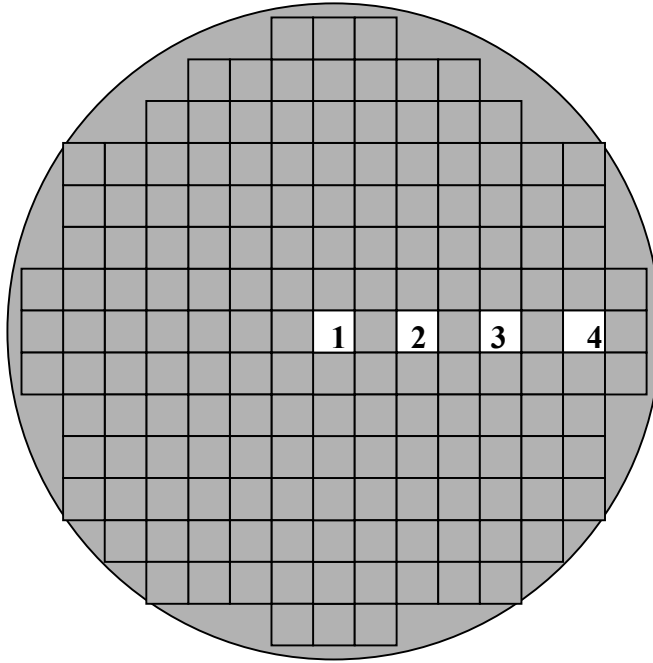


Basic Oxide Thickness Measurement Plan

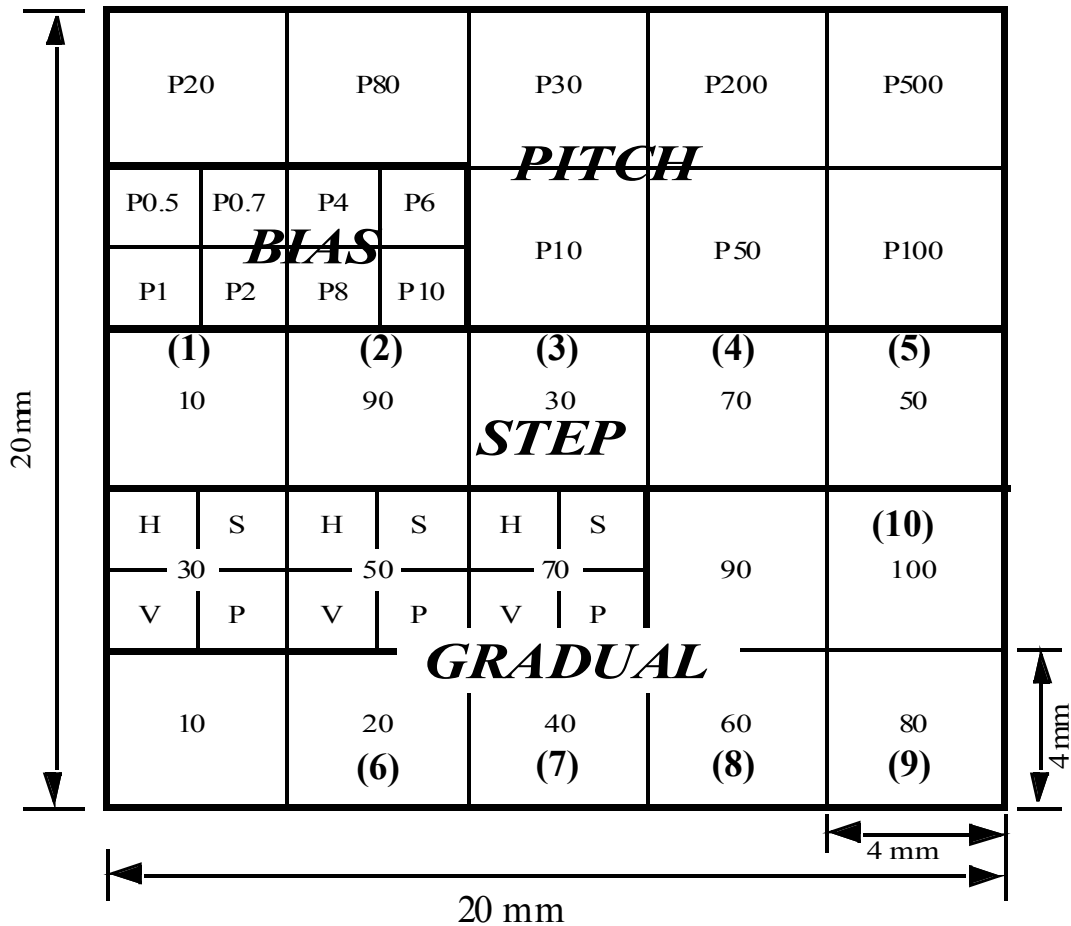
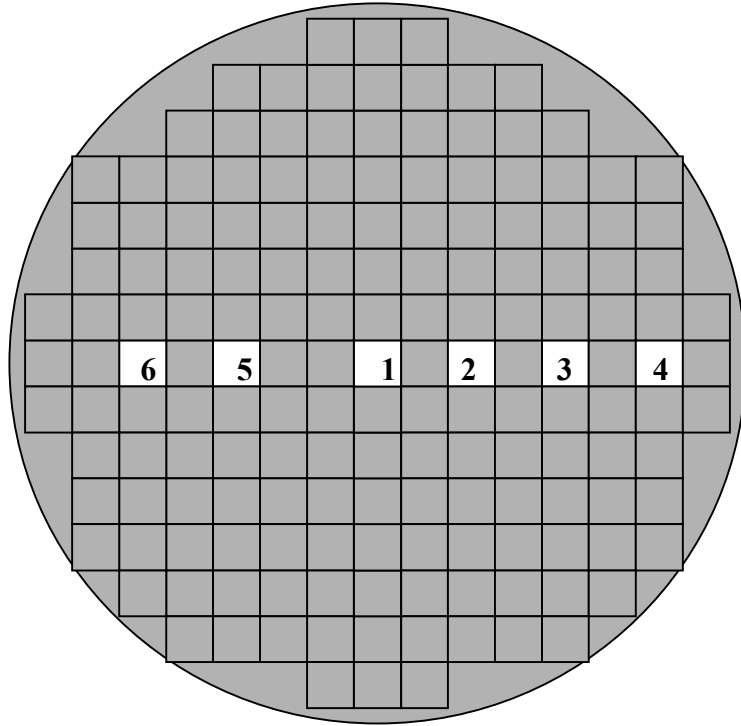
(Type: SKW 7-2, 300mm, 4 dies/wafer, 9 sites/die)



SKW 7-2 Mask Floor Plan

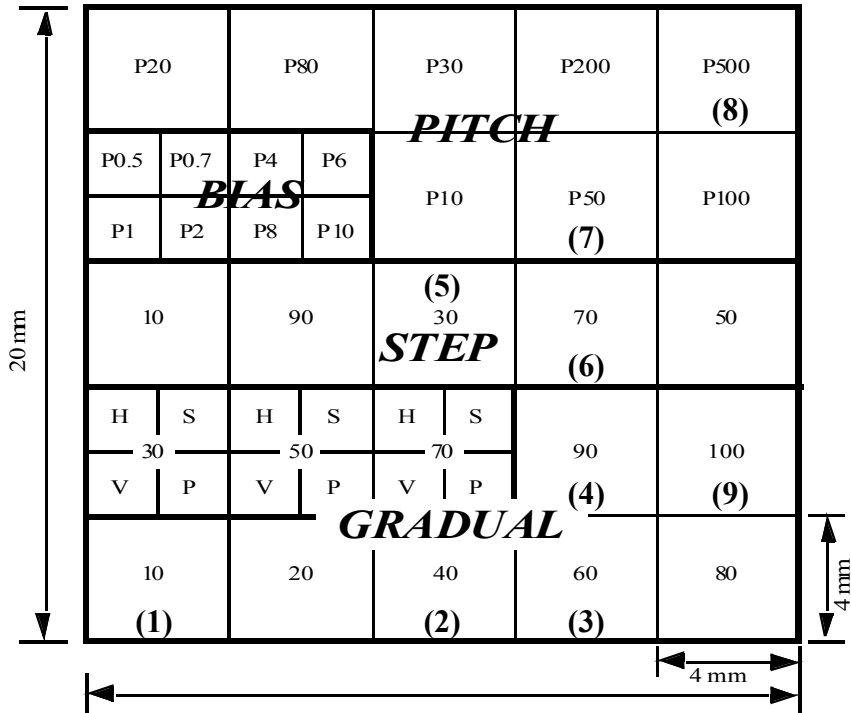
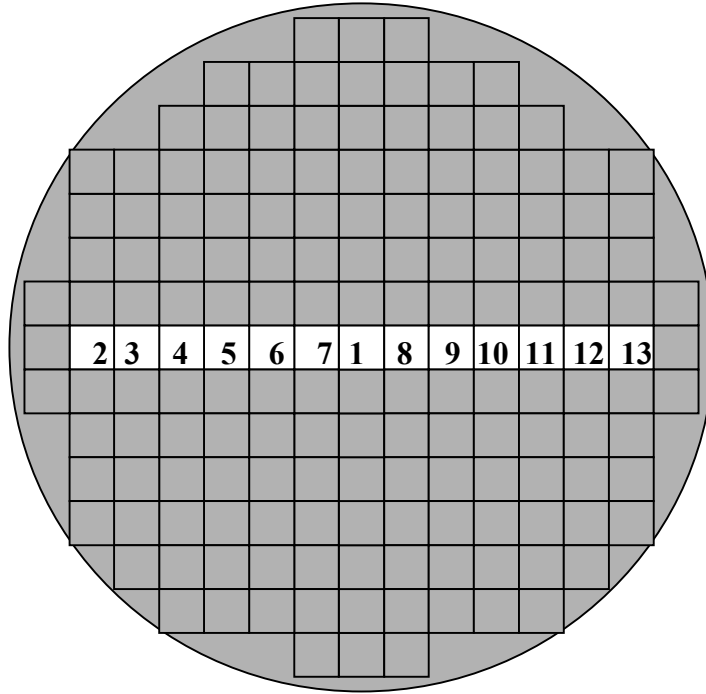
Standard Oxide Thickness Measurement Plan

(Type: SKW 7-2, 300mm, 6 dies/wafer, 10 sites/die)



Advanced Oxide Thickness Measurement Plan

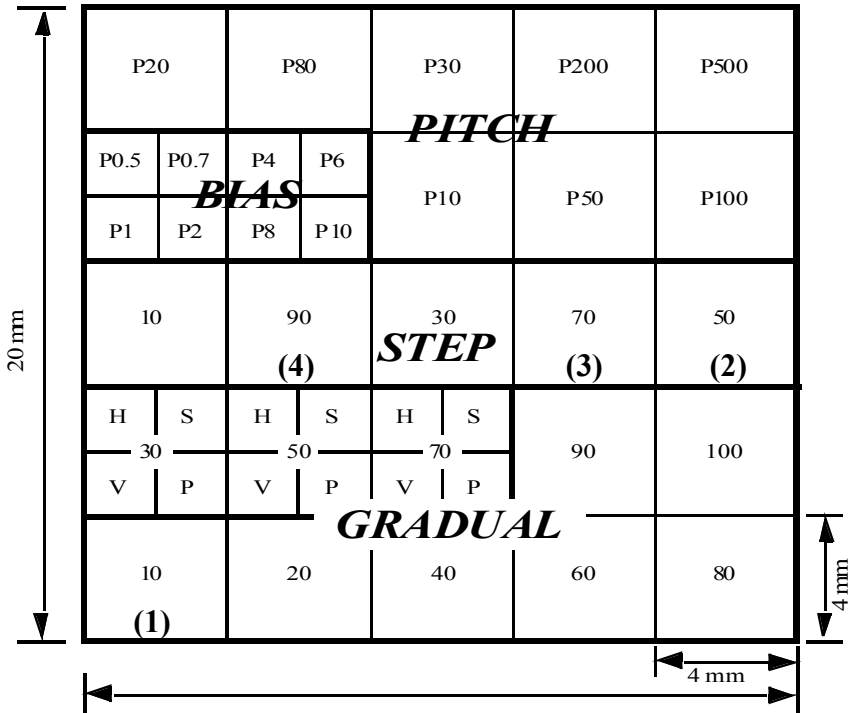
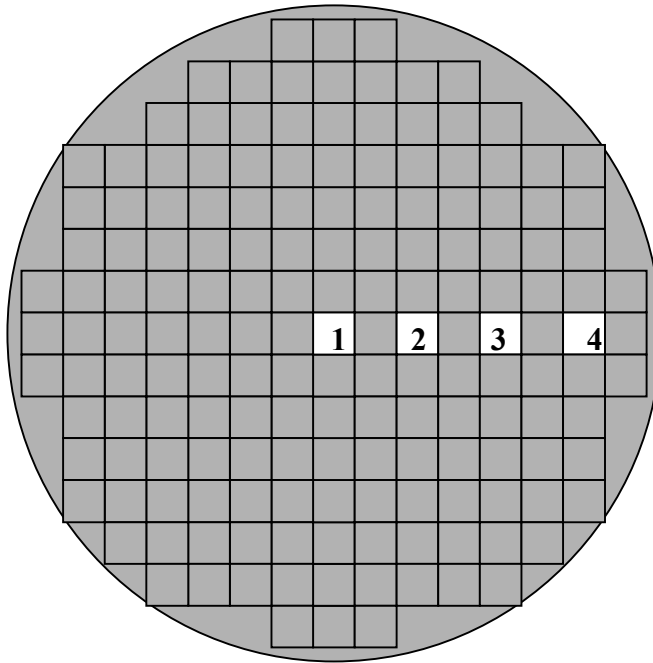
(Type: SKW 7-2, 300mm, 13 dies/wafer, 9 sites/die)



SKW 7-2 Mask Floor Plan

Basic Step Height Measurement Plan

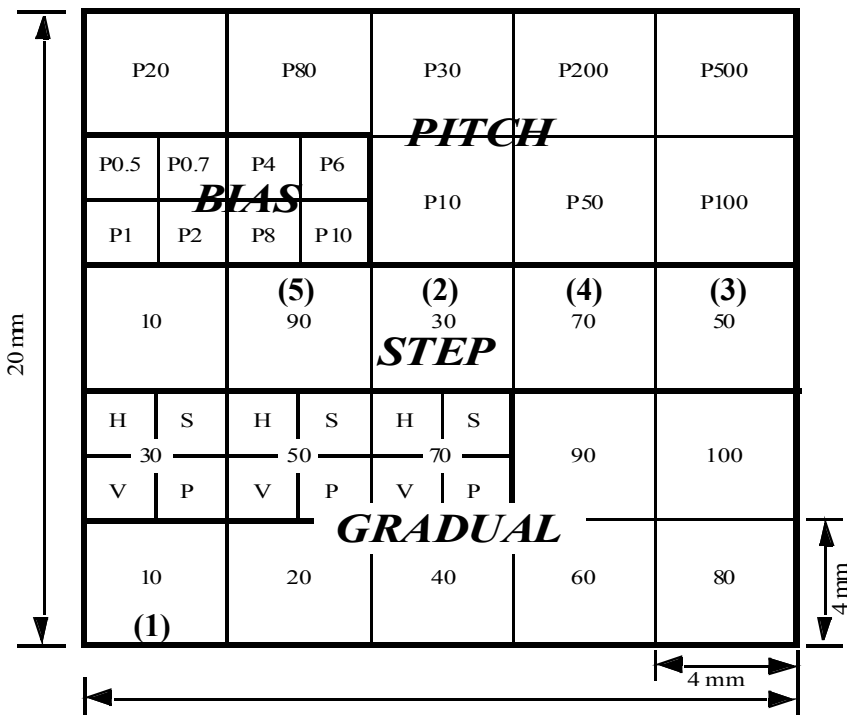
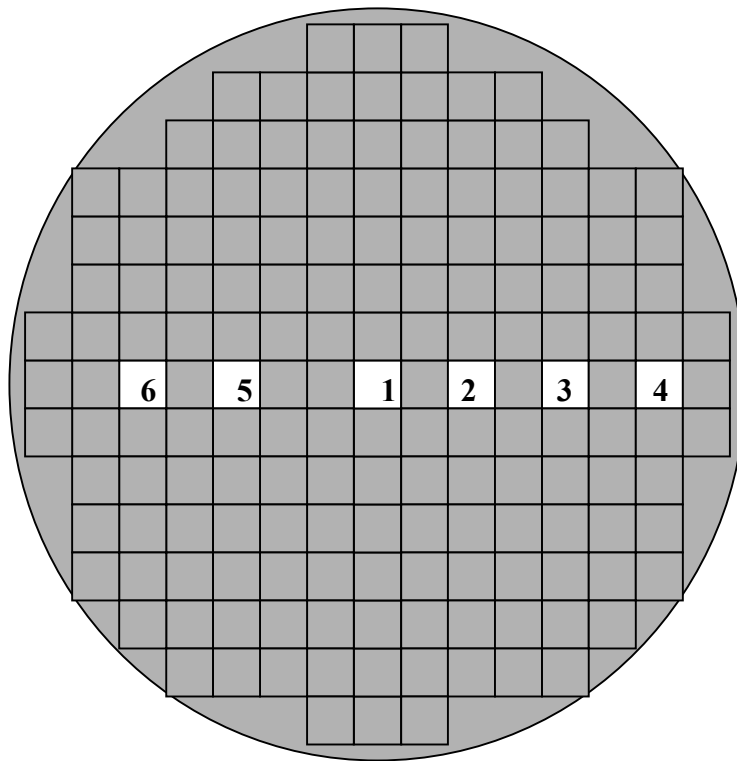
(Type: SKW 7-2, 300mm, 4 dies/wafer, 4 sites/die)



SKW 7-2 Mask Floor Plan

Advanced Step Height Measurement Plan

(Type: SKW 7-2, 300mm, 6 dies/wafer, 5 sites/die)



SKW 7-2 Mask Floor Plan